STRUCTURAL, MAGNETIC AND MAGNETO-TRANSPORT PROPERTIES OF EQUIATOMIC CoFeMnSi EPITAXIAL THIN FILMS

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I. INTRODUCTION

Half-metallic ferromagnetic (HMF) materials have fully spin polarized band structures and therefore suitable for spintronic applications [1]. Among the large families of HMF materials, Co-based Heusler alloys attracted a lot of attention due to their theoretically predicted half-metallic nature and experimentally observed high spin polarization with high Curie temperatures [1-6]. Equiatomic quaternary Heusler alloys (EQHAs), with Y-type crystal structure are relatively new class of materials and explored very little [7,8]. Depending on the occupation of different lattice sites, there are three types of structural configurations are possible for a Y-type structure [8]. In addition, EQHAs (such as ABCD, where A, B and C are the transition-metal elements and D is a main group element) are prone to possess a various type of chemical disorder. When there is mixing of A and B (A=B), the material becomes Heusler-type L2₁ alloy with the composition of A₂CD. Therefore, when A=B in an EQHAs, it is referred as a L₂₁ ordered system. Another type of possible disorder is C-D disorder, and termed as B₂ ordered system. The third type of possible disorder is A₂ (bcc) disorder, where all the atoms are randomly distributed. Properties of these materials greatly depend on the chemical ordering in the system. CoFeMnSi (CFMS) is one of the EQHAs, which has been predicted as a spin gapless semiconductor [9,10] and the spin-polarization was relatively high, evaluated by the Point-Contact Andreev Reflection in bulk form [10]. However, there are no reports available on magnetic tunnel junctions (MTJs) with CFMS thin film electrode. In this study, we investigate the structural and magnetic properties of CFMS epitaxial thin films with tunnel magneto-resistance (TMR) for MTJs.

II. EXPERIMENTAL DETAILS

30 nm thick CFMS films were grown on single crystalline (001) MgO substrate buffered by 40 nm thick Cr layer using the UHV magnetron sputtering system with a base pressure of less than 2 × 10⁻⁷ Pa. Samples with CFMS post-annealed (Tₐ) at 300, 400, 500 and 600°C were prepared. The composition of the deposited CFMS films was confirmed to be Co₂₄Fe₂₄Mn₂₄Si₂₆ (at. %) using the inductively coupled plasma (ICP) analysis, which is almost ideal stoichiometric composition for EQHAs.

III. RESULTS AND DISCUSSION

The in-plane XRD patterns show CFMS (200) and (400) peaks for samples with Tₐ ≥ 400°C as shown in Fig. 1(a), which indicates that the films are grown with high degree of crystal orientation with respect to MgO (001). Crystallinity of the thin films improves with increase in the Tₐ. The respective L₂₁ and B₂ order parameters for CFMS could be obtained by using the extended Webster model [11]. The respective B₂ and L₂₁ orders are estimated using the long-range order parameters 

\[ S_{B₂}² = \frac{I_{002} / I_{004}}{I_{002} / I_{004}} \] and \[ S_{L₂₁}² (3 - S_{B₂}²) / 2 = \frac{I_{111} / I_{220}}{I_{111} / I_{220}} \],

where \( I_{hkl} \) and \( I_{hkl}^R \) are the experimental X-ray diffraction intensity for (hkl) plane and reference intensity calculated for a fully ordered system, respectively. The estimated order parameters are shown in Fig. 1(b). ϕ scan for (111) and (220) plane was performed by tilting the sample [χ = 54.7° for (111) plane and χ = 45° for (220) plane], which shows a fourfold symmetry for samples with Tₐ ≥ 400°C and thus confirms epitaxial growth of CFMS thin films. In order to get the intensity of CFMS (111) and (220) diffraction peaks, 2θ-θ scan was performed with χ=54.7° and χ=45°. These data indicate that the CFMS films contain the B₂ and L₂₁ long range orders that change with the Tₐ. Because of almost similar scattering factors for Co and Fe, it is virtually impossible to distinguish between Y-type and L₂₁ ordering.
using the Cu-Kα radiation.

All the films show in-plane magnetic anisotropy. Saturation magnetization ($M_s$) value increases with increase in $T_a$ and it attains a value of 590 emu/cm$^3$ for sample with $T_a = 600^\circ$C. The obtained $M_s$ value is less than the experimental observed $M_s$ (690 emu/cm$^3$) value for bulk CFMS case [10]. These magnetization data are in accord with x-ray magnetic circular dichroism measurements (XMCD). Coersive field ($H_C$) value also changes with $T_a$, and attains $H_C = 10$ Oe for $T_a = 600^\circ$C sample. Thus, samples with $T_a \geq 500^\circ$C exhibit a soft ferromagnetic behavior similar to other Heusler alloys [2-4,6], therefore they have a high potential for magnetic sensor applications. We emphasize that the samples with high crystallinity represent high $M_s$ and low $H_C$ values.

Tunneling magneto-resistance effect measurements were performed on the MTJs with optimized growth conditions. The stacking structure of MgO(001) substrate/Cr(40 nm)/CFMS(30 nm)/Mg(0.4 nm)/MgO(1.6 nm)/CoFe(5 nm)/IrMn(10 nm)/Ta(3 nm)/Ru(5 nm) was used for TMR studies. In order to improve the crystallinity of MgO barrier and to obtain exchange bias, MTJs were annealed after the microfabrication in presence of in-plane magnetic field (5 kOe) at different temperatures. TMR was observed with respect to the ex-situ annealing. Preliminary measurements on the MTJs show maximum TMR ratio of 70% for the ex-situ annealing of 450$^\circ$C.

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REFERENCES


Fig. 1. (a) In-plane XRD measurements. (b) Experimental ($I_{111}/I_{220}$ and $I_{002}/I_{004}$) and calculated intensity ratios ($I_{111}/I_{220}$ and $P_{002}/P_{004}$) with respect to $T_a$ are plotted on the left-hand scale, while percentages of ordering parameters are plotted on the right-hand scale.